

BUR920040040US



IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Anderson, et al.

Serial No. 10/711,170

Group Art Unit: Unknown

Filing Date: 8/30/04

Examiner: Unknown

For: FINFET WITH LOW GATE CAPACITANCE AND LOW EXTRINSIC
RESISTANCE

Commissioner of Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:

Under the provisions of 37 CFR §1.97 through §1.99 and pursuant to applicants' duty of disclosure under 37 CFR §1.56, applicants respectfully bring the following documents, listed on the attached form PTO-1449, to the attention of the Examiner in charge of the above-identified application. Copies of the listed documents are provided herewith for the convenience of the Examiner. This citation does not constitute an admission that the references are relevant or material to the claims. They are only cited as constituting related art of which the applicants are aware.

It is respectfully requested that the listed references be considered by the Examiner and formally made of record in this application.

Please charge any deficiencies in fees and credit any overpayment of fees to Attorney's

Deposit Account No. 09-0456.

Respectfully submitted,

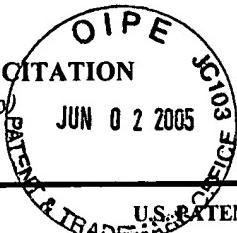
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INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

JUN 02 2005



Docket Number (Optional)

BUR920040040US1

Application Number

16/71170

Applicant(s)

Anderson, et al.

Filing Date

8/30/04

Group Art Unit

Unknown

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

Lindert, et al., "Sub-60-nm Quasi-Planar FinFETs Fabricated Using a Simplified Process", IEEE Electron Device Letters, Vol. 22, No. 10, October 2001, Pages 487-489

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.